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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/615,293 07/09/2003		Kazunori Komatsu	Q76485	7080	
23373	7590 07/29/2004	EXAMINER			
SUGHRUE MION, PLLC 2100 PENNSYLVANIA AVENUE. N.W.			UHLIR, NIKOLAS J		
SUITE 800	· 12 · 11 · 11 · 11 · 12 · 10 2 · ,	ART UNIT	PAPER NUMBER		
WASHINGTON, DC 20037			1773		

DATE MAILED: 07/29/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application N	ю.	Applicant(s)	(/\		
Office Action Summary		10/615,293		TOGASHI, KOJI			
		Examiner	\\\\\\\\	Art Unit			
		Nikolas J. Uhli	ir	1773			
Period fo	The MAILING DATE of this communication a or Reply	ppears on the co	ver sheet with the c	orrespondence addres	S		
A SH THE - Exte after - If the - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REF MAILING DATE OF THIS COMMUNICATION nsions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a roperiod for reply is specified above, the maximum statutory perior to reply within the set or extended period for reply will, by state reply received by the Office later than three months after the mailed patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, h eply within the statutory od will apply and will exp ute, cause the application	owever, may a reply be tim minimum of thirty (30) day: ire SIX (6) MONTHS from on to become ABANDONE!	nely filed s will be considered timely. the mailing date of this commu D (35 U.S.C. § 133).	nication.		
Status							
1)[Responsive to communication(s) filed on	·					
-	This action is FINAL. 2b)⊠ This action is non-final.						
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dienocit	ion of Claims	. Ex parto quay.	,, 1000 0.2,				
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4)[2]	 ✓ Claim(s) <u>1-4</u> is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 						
5)[]	Claim(s) is/are allowed.	, , , , , , , , , , , , , , , , , , , ,	, 0.1 — 1.1				
,	Claim(s) 1-4 is/are rejected.						
7)	Claim(s) is/are objected to.						
8) 🗌	Claim(s) are subject to restriction and	d/or election requ	irement.				
Applicat	ion Papers						
,—	The specification is objected to by the Exami						
10)[The drawing(s) filed on is/are: a) a						
	Applicant may not request that any objection to the						
11)	Replacement drawing sheet(s) including the corr The oath or declaration is objected to by the						
Priority	under 35 U.S.C. § 119						
12)⊠	Acknowledgment is made of a claim for forei ☑ All b) ☐ Some * c) ☐ None of:	gn priority under	35 U.S.C. § 119(a))-(d) or (f).			
	1. ☐ Certified copies of the priority docume						
	2. Certified copies of the priority docume						
	3. Copies of the certified copies of the p			ed in this National Stat	је		
* :	application from the International Bure See the attached detailed Office action for a l			ed.	•		
·	See the attached detailed emed described at	5 55 65					
Attachmei	nt(s)						
	ce of References Cited (PTO-892)	4)	Interview Summary				
	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/0	₀₈₎ 5)	Paper No(s)/Mail Da Notice of Informal F	ate Patent Application (PTO-152	<u>'</u>)		
	er No(s)/Mail Date <u>07/09/03; 1/14/04</u> .	6)	Other:				

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1-4 are rejected under 35 U.S.C. 102(b) as being anticipated by Ishida (WO98/03972).
- 3. US6347016 is an English equivalent to WO98/03972 and is used herein as an English translation of the WO document. All references to Ishida refer to the US document. It is noted that WO98/03972 was published on Jan 29, 1998.
- 4. Claim 1 requires a master information carrier having thereon a pattern of a magnetic layer representing information to be transferred to a high-density recording slave medium where the track width is not larger than 0.3µm, wherein the improvement comprises that the pattern is drawn by scanning a given track a plurality of times with an electron beam whose drawing diameter is smaller than the track width.
- 5. The limitation "wherein the improvement comprises.... smaller than the track width" is a process limitation in a product claim and does not appear to be further limiting in so far as the structure of the product is concerned. Even though product claims are limited by and defined by the process, determination of patentability is based on the product itself. The patentability of a product does not depend on its method of production. If the product in the claim is the same as or obvious from a product of the prior art, the claim is unpatentable even though the prior product was made by a different

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process." *In re Thorpe*, 777 F.2d 695, 698, 227 USPQ 964, 966 (Fed. Cir. 1985). See MPEP § 2113.

- 6. The applicant in the instant specification provides no data that establishes that a master medium produced via multiple passes of an electron beam having a write diameter that is smaller than that of the track width is structurally different from that of a master medium produced by a different process. Applicant's in their instant specification have discussed that laser ablation/lithography results in the protrusion portions of the pattern having rounded edges, whereas the method of the instant invention does not. However, magnetic masters are produced by a variety of methods other than laser ablation/lithography. Applicant has provided no data that establishes that the claimed multi pass electron beam method results in a master medium that is structurally different from a master medium that is manufactured by one of these alternative processes.
- 7. Bearing the above in mind, Ishida teaches a magnetic master comprising a substrate with a patterned magnetic layer on its surface. The pattern is formed in the surface of the master via lithography with a laser or an electron beam. In one embodiment, the width of the protuberance portions of the patterned magnetic layer (known to be equivalent to the track width) are 0.2μ (see figure 10). Ishida teaches that the protuberances should have a rectangular cross section, as shown in figure 3 (column 15, lines 59-67). However, Ishida teaches that if the master having protuberances width of 0.2μ is formed utilizing laser ablation/lithography, the protuberance will have curved edges, as the resolution of the developing process is insufficient (figure 10, lines 1-10). While the Ishida reference primarily focuses on the use of laser ablation/lithography

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because it is relatively inexpensive, Ishida teaches that the undesirable curved edge profile can be avoided through the use of a more advance lithographic technique.

- 8. From the above-cited portions of Ishida, it is clear that the Ishida reference anticipates all of the product limitations of claim 1.
- 9. The limitations of claims 2-4 merely further limit the process of claim 1 and do not appear to further limit the structure of the claimed product. Accordingly, these limitations are met as set forth above for claim 1.

Double Patenting

10. The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and, *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

11. Claim 1 is provisionally rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claim 1 of copending Application No. 10/192849. Although the conflicting claims are not identical, they are not patentably distinct from each other because the limitations of claim 1 of the copending application fall entirely within the scope of the instant application. The only difference between claim one of the copending application and claim one of the instant application is that the claim 1 of the copending application requires the patterned magnetic layer to

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be a soft magnetic material. Soft magnetic materials are completely encompassed by the language of claim 1 of the instant application, which requires a generic patterned magnetic layer.

This is a <u>provisional</u> obviousness-type double patenting rejection because the conflicting claims have not in fact been patented.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Nikolas J. Uhlir whose telephone number is 571-272-1517. The examiner can normally be reached on Mon-Fri 7:30 am - 5 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Paul J. Thibodeau can be reached on 571-272-1516. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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Paul Thibodeau Supervisory Patent Examiner Technology Center 1700

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